

# MARINE & PROTECTIVE COATINGS FORMULATIONS

## Resins and additives for waterborne and solventborne systems

SYSTEM	ADHESION	DEAERATION/ DEFOAMING	FLOW & LEVELING	LONG DURABLE MAIN BINDER	HARDENER	MATTING	PIGMENT WETTING	RHEOLOGY	SUBSTRATE WETTING
Waterborne	TEGO® AddBond DS 1300	TEGO® Airex 901 W AIRASE® 8070 TEGO® Foamex 810 TEGO® Foamex 823	TEGO® Flow 425 TEGO® Wet 270 TEGO® Glide 100 TEGO® Glide A 116			ACEMATT® TS 100 ACEMATT® OK 412 ACEMATT® OK 520 ACEMATT® HK 520 ●	TEGO® Dispers 755 W* TEGO® Dispers 760 W* ZETASPERSE® 3600 TEGO® Dispers 757 W	AEROSIL® 200 AEROSIL® R 972 AEROSIL® E 972 ● AEROSIL® E 805 ● AEROSIL® E 812 ●	TEGO® Twin 4200 SURFYNOL® AD01 SURFYNOL® 420 TEGO® Wet 270
Solventborne	TEGO® AddBond LTH TEGO® AddBond LP 1611 TEGO® AddBond LTW	TEGO® Airex 991 TEGO® Airex 990 TEGO® Airex 944	TEGO® Glide 450 TEGO® Glide 100 TEGO® Flow 375	SILIKOPON® EF SILIKOPON® ED SILIKOTOP® E 901	TEGO® Cure 100 ●	ACEMATT® TS 100 ACEMATT® OK 412 ACEMATT® OK 520 ACEMATT® HK 520 ●	TEGO® Dispers 670** TEGO® Dispers 673* TEGO® Dispers 628** TEGO® Dispers 679*	AEROSIL® R 202 AEROSIL® R 972 AEROSIL® E 972 ● AEROSIL® E 805 ● AEROSIL® E 812 ●	SURFYNOL® AD01 TEGO® Wet 280 TEGO® Wet 270 TEGO® Twin 4100

● new product \*organic pigments \*\*inorganic pigments

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